Theory of Charge Transport in Mixed Conductors: **Description of Interfacial Contributions Compatible with** the Gibbs Thermodynamics Mikhail A. Vorotyntsev LSEO-UMR 5188 CNRS, Université de Bourgogne, Dijon, France

# Content

- Introduction: mixed transport.
- Randles impedance. Interfacial capacitance. Formulation of the problem.
- Thermodynamics of charged interfaces. Conditions at interfaces for transport.
- Analytical expressions for impedance. Graphical illustrations.
- New systems: "mixed interfacial exchange".
- Conclusions.

#### medium 1

#### film : 2 mobile species plus fixed charges

#### medium 2

# Film (f):

- conducting or redox polymers,
- electron-ion conducting oxides/hydrids/sulfides,
- Li<sup>+</sup> & Mg<sup>++</sup> intercalation layers,
- solid electrolytes,
- thin layers of a binary solution.

#### Species :

- electronic and ionic (e, i) plus fixed charge,
- cations and anions.

### Media 1 et 2 :

- electronic conductor ( m ),
- ionic conductor (s).

# Tree types of systems :

- **m/f/m'** : between two electronic conductors,
- s'/f/s : "membrane geometry",
- **m/f/s** : "modified electrode"

# Electrochemical Impedance Spectroscopy

- transport properties,
- interfacial characteristics

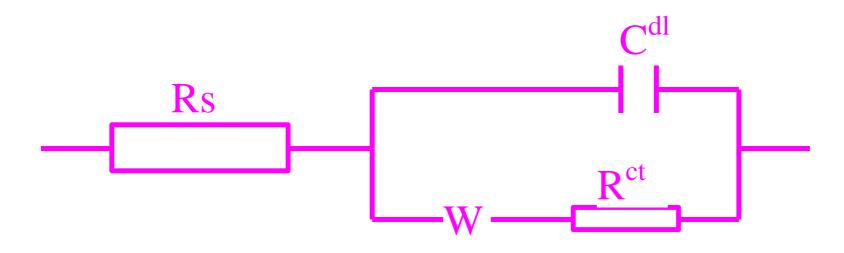
# Based on :

- analytical analysis,
- equivalent circuit.

# To be included :

- bulk film transport,
- charge transfer across the interfaces ("faradaic"),
- charge of interfaces (charge of "double layers")

Randles Impedance : metal / solution Supporting electrolyte + Redox species



**General hypothesis**:

- consider the process without interfacial charge,

- add "double layer capacitance" C<sup>dl</sup> parallel to the "faradaic branch".

System containing only <u>two</u> mobile species:

- no supporting electrolyte,

- the <u>same</u> species participate at each interface
  - in the "**faradaic" process**

(redox reaction or ion exchange)

#### as well as

- in the **interfacial charge** 

these two processes are coupled to the same transport process (Warburg element).

Another complication :

 $\begin{array}{c|c} \mbox{metal} & EDL & \mbox{diffusion} & \mbox{bulk solution} \\ \mbox{$\sigma$} & \mbox{$\sigma$}_{+}\,, \mbox{$\sigma$}_{-} & \mbox{layer} & \mbox{$i_k = t_k$}\ i \end{array}$ 

Composition of the double layer (charges  $\sigma_+$ ,  $\sigma_-$ ) is determined by **properties of the interface**.

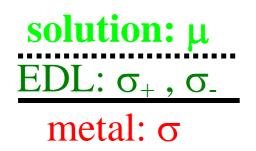
Partial currents  $i_k$  in the bulk solution are determined by **transport numbers**  $t_k$ .

This discrepancy of the partial currents and the variation of charges  $\sigma_+$ ,  $\sigma_-$  must be compensated by the diffusion layer

its impedance (analogue of W) must be a **function of t**<sub>k</sub> as well as **of parameters determining**  $\sigma_+$  and  $\sigma_-$ 

Conclusion : **capacitance** C<sup>dl</sup> **is not sufficient** to characterize the charging of interfaces !

<u>Thermodynamics of interfaces – binary solution</u>: 2 independent variables, e.g.  $\sigma \& \mu = \mu_+/z_+ - \mu_-/z_-$ 



$$\begin{split} dE_{+} &= (C^{dl})^{\text{-1}} \ d\sigma \text{ - } t_{\text{-}}^{\ dl} \ d(\mu/F) \\ d\sigma_{+} &= \text{-} t_{+}^{\ dl} \ d\sigma \text{ - } C_{\mu}^{\ dl} \ d(\mu/F) \\ d\sigma_{\text{-}} &= \text{-} t_{\text{-}}^{\ dl} \ d\sigma \text{ + } C_{\mu}^{\ dl} \ d(\mu/F) \end{split}$$

**THREE** independent interfacial parameters:

(1) **C<sup>dl</sup>**, interfacial capacitance ("capacitance of the electrical double layer"),

(2)  $\mathbf{t}_{+}^{dl}$  et  $\mathbf{t}_{-}^{dl}$ , "interfacial numbers of species" :  $\sigma_{+} + \sigma_{-} = -\sigma \implies t_{+}^{dl} + t_{-}^{dl} = 1$ The same coefficient  $t_{-}^{dl}$  for  $dE_{+}$  et for  $d\sigma_{-}$ ,

(3)  $C_{\mu}^{dl}$ , "asymmetry factor of the interfacial charge"

# **Electrolyte without specific adsorption** : theory of Gouy-Chapman-Grahame

- these parameters are functions of  $\sigma$  and  $\mu$ ,
- generally,  $C_{\mu}^{dl} \sim C^{dl}$ ;  $0 \le t_{+}^{dl}$ ,  $t_{-}^{dl} \le 1$  **Specific adsorption**:  $t_{k}^{dl} < 0$  or  $t_{k}^{dl} > 1$  $i_{k}(0,t) = i_{k}^{dl} + i_{k}^{ct}$
- $i_k^{dl} = d\sigma_k / dt$
- $i_k^{ct} = [\mu_k^{ext} \mu_k(0,t)] / z_k F R_k^{ct} \equiv (E_k E_k^{o}) / R_k^{ct}$

#### **Transport equations + conditions at interfaces**

Their combined solution gives <u>analytical expressions</u> of impedance  $Z(\omega)$  for 3 geometries of the system : **m/f/m'** (different metals), **m/f/s**, **s'/f/s**.

**m/f/m** : film between two identical metals  $Z^{m/f/m} = R_f + 2 Z^{m/f} + 4 W_f (\delta t_i)^2 [\operatorname{coth} v + F^{m/t}]^{-1}$  $Z^{m/f} = (1 / R_e^{m/f} + i\omega C^{m/f})^{-1}$  $W_f = \Delta R_f v^{-1}$ ;  $v = (j\omega L^2 / 4D)^{1/2}$  $\delta t_i = t_i - t_i^{m/f} (1 - g^{m/f}); g^{m/f} = (1 + i\omega R_e^{m/f} C^{m/f})^{-1}$  $F^{m/f} = 2 W_f j\omega [(t_i^{m/f})^2 g^{m/f} C^{m/f} - C_m^{m/f}]$ 

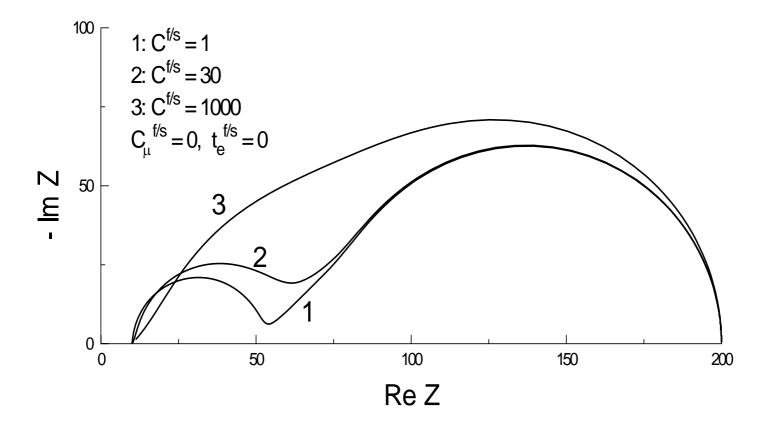
**m/f/s** : film between a metal and a solution

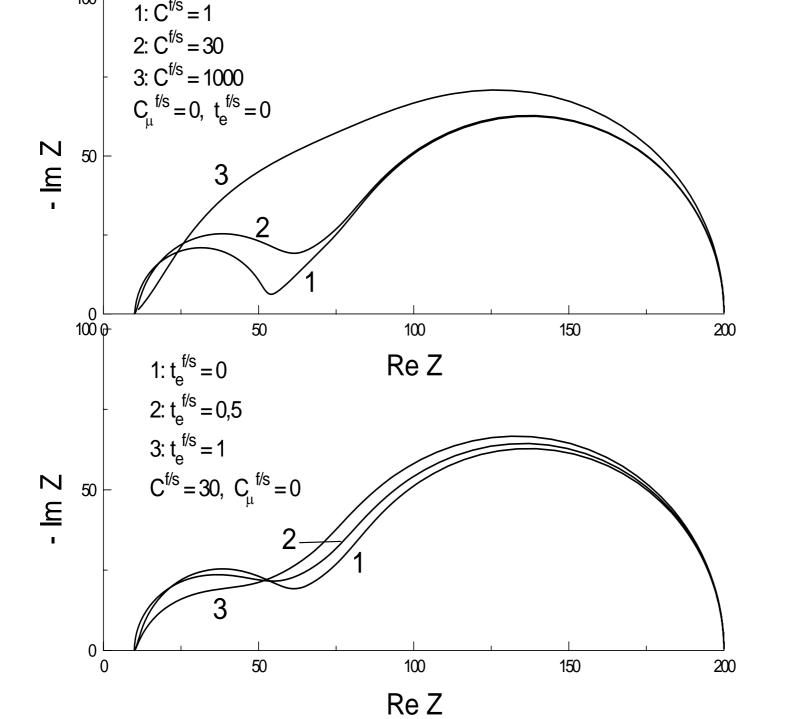
# $Z^{m/f/s} = R_s + R_f + Z^{m/f} + Z^{f/s} + 2 W_f Z_a / Z_b$

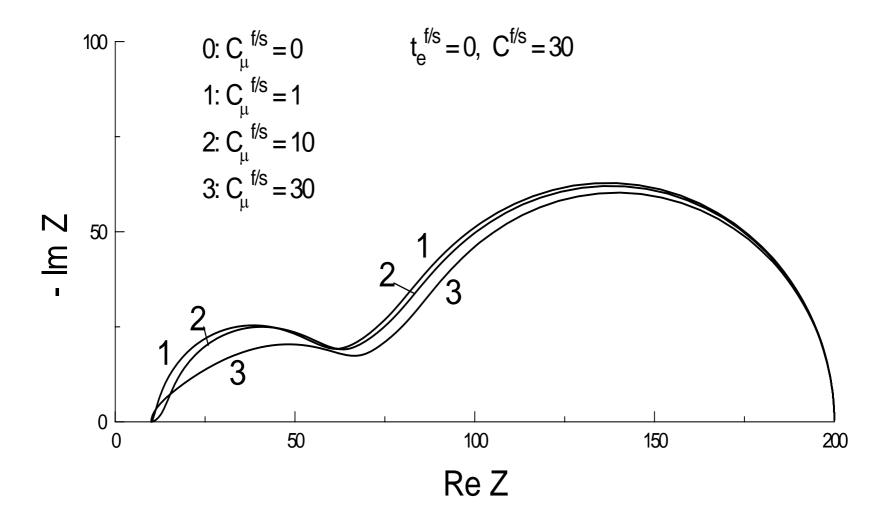
$$\begin{split} &Z_a = (\ \delta t_i \ )^2 \ (\ \coth 2\nu + F^{f/s} \ ) + 2 \ \delta t_i \ \delta t_e \ (\ \sinh 2\nu \ )^{-1} \\ &+ (\ \delta t_e \ )^2 \ (\ \coth 2\nu + F^{m/f} \ ) \ ; \\ &Z_b = 1 + (\ F^{m/f} + F^{f/s} \ ) \ \coth 2\nu + F^{m/f} \ F^{f/s} \end{split}$$

s/f/s : particular case,  $t_e^{f/s} = 0$ ,  $C_{\mu}^{f/s} = 0$   $Z^{s/f/s} = R_f + 2 Z^{f/s} + 4 W_f t_e^2 \tanh v$   $Z^{f/s} = (1 / R_i^{f/s} + j\omega C^{f/s})^{-1}$  $W_f = \Delta R_f v^{-1}$ ;  $v = (j\omega L^2 / 4D)^{1/2}$ 

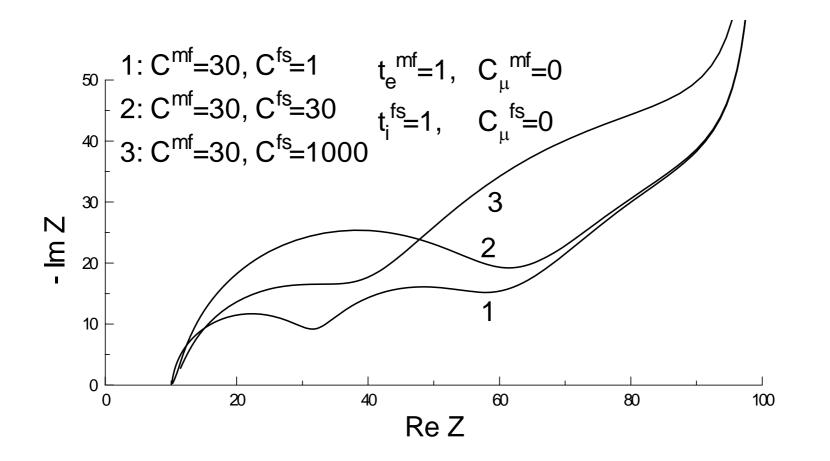
# Symmetrical membrane geometry: film between two identical solutions, s/f/s

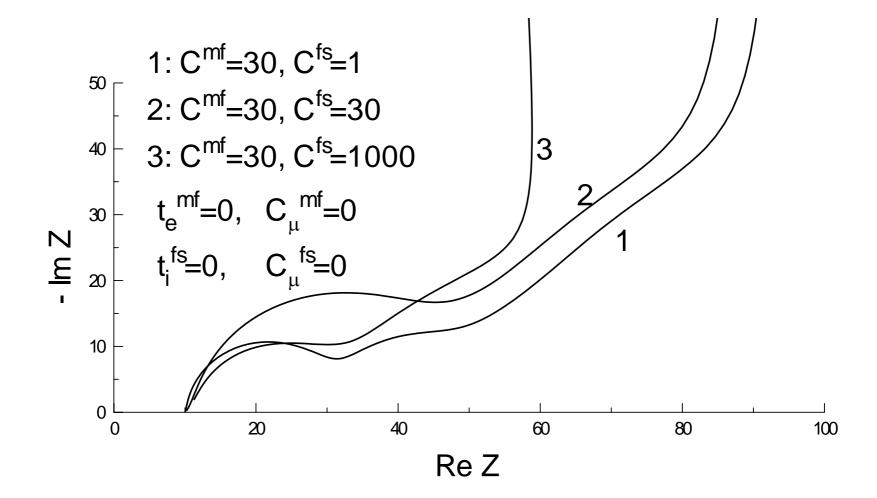


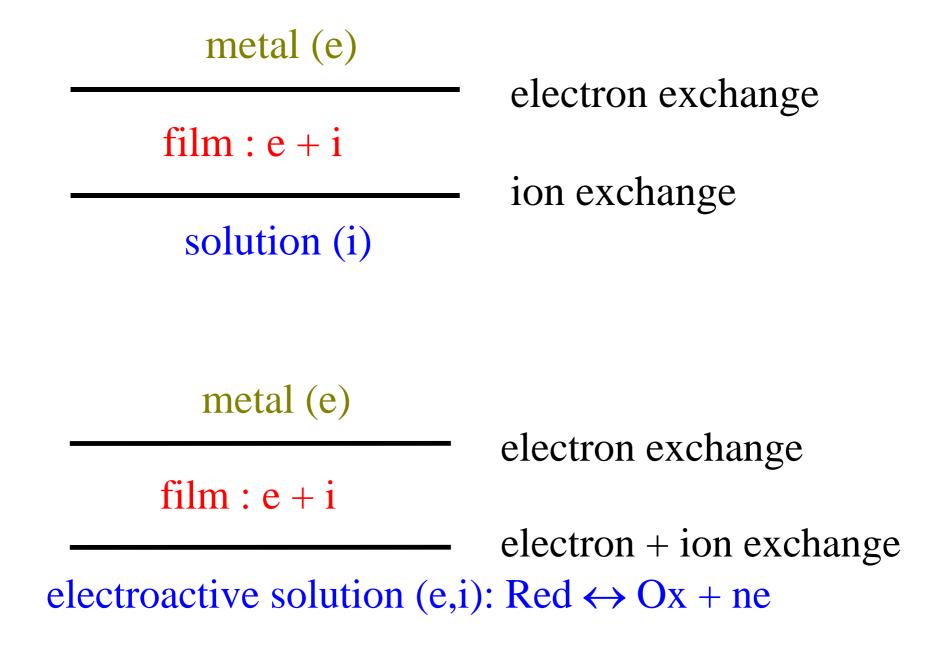




Modified Electrode Geometry: film between a metal and a solution, m/f/s







New geometries: m/f/es, es'/f/es, s/f/es

Similar treatment of boundary conditions for transport

Analytical solutions for all new geometries

New experimental possibilities: one can obtain impedance data for numerous systems having the same values of the bulk film and interfacial parameters

#### **CONCLUSIONS**

- there is no simple way to insert the contribution of the interfacial charge in the final expression for complex impedance.

- contrary to expectations, interfacial capacitance  $C^{dl}$  is not sufficient to characterize this contribution : impedance also depends on interfacial numbers  $t_{\pm}^{dl}$  as well as parameter  $C_{\mu}^{dl}$ . thin film with a mixed conductivity : one can obtain analytical expressions Z(ω) in the cases :
1. between two metals (identical or different),
2. between two solutions ("membrane geometry"),
3. between a metal and a solution ("modified electrode").

- if the charging of the double layer is realized completely by the "faradaic" species, the effect of the interfacial charge is very simple : capacitance  $C^{dl}$  in parallel to  $R_e^{m/f}$  or  $R_i^{f/s}$ .

- <u>general case</u> : impedance plots are markedly deformed with respect to this simple case.

Application of simplified formulae can lead to serious errors in the value of capacitance C<sup>dl</sup> found from the treatment of experimental data.

- new prospects to extract the bulk-film and interfacial parameters of the system are provided by "non-traditional" arrangements, films in contact with "electroactive solutions".

Analytical formulae for complex impedance are now available for all possible 1D geometries: m'/f/m, s'f/s, m/f/s, m/f/es, es'/f/es, s/f/es